

Giant magnetoresistance in magnetic metallic multilayers

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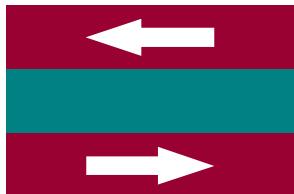
- Funded by Hewlett-Packard Laboratories, Palo Alto, CA

Synopsis

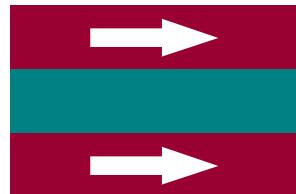
- Introduction
- Physical origin
- The theoretical model
- Co/Cu and Fe/Cr multilayers
- Application to experiments:
 - Thermoelectric power
 - Thickness-dependent conductance
 - Interface resistance
- Conclusions

Giant magnetoresistance (GMR)

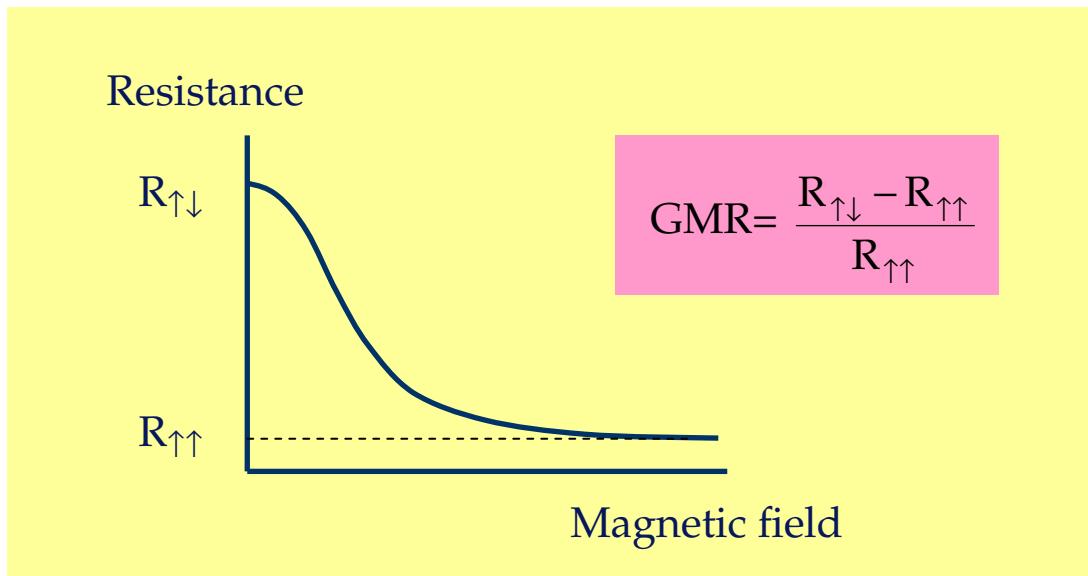
Antiparallel
magnetizations



Parallel
magnetizations

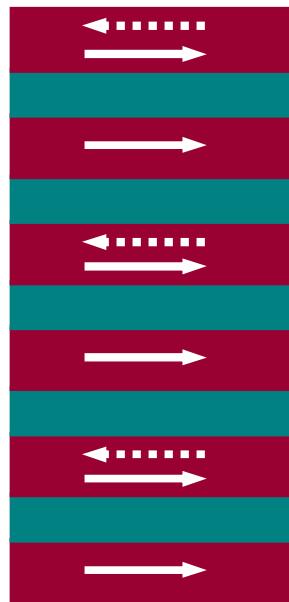


Ferromagnet (Co)
Nonmagnetic metal (Cu)
Ferromagnet (Co)



GMR structures

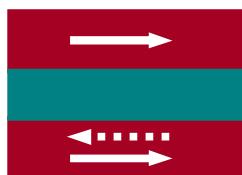
Magnetic multilayer



FM (ferromagnetic layer)
NM (nonmagnetic metallic layer)
FM
NM
FM
NM
FM
NM
FM
NM
FM

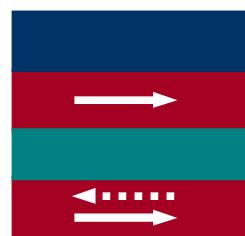
- ◆ antiferromagnetic exchange coupling
- ◆ highest values of GMR, in Co/Cu and Fe/Cr multilayers ~ 100%

Pseudo spin valve



FM - hard
NM
FM - soft

Spin valve



AF (antiferromagnet)
FM - pinned
NM
FM - free

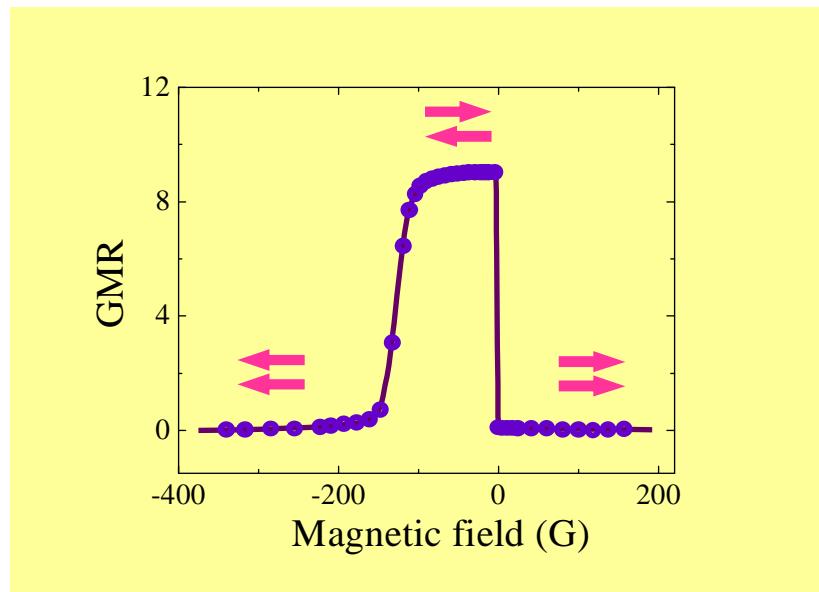
- ◆ different coercivities

- ◆ exchange biasing

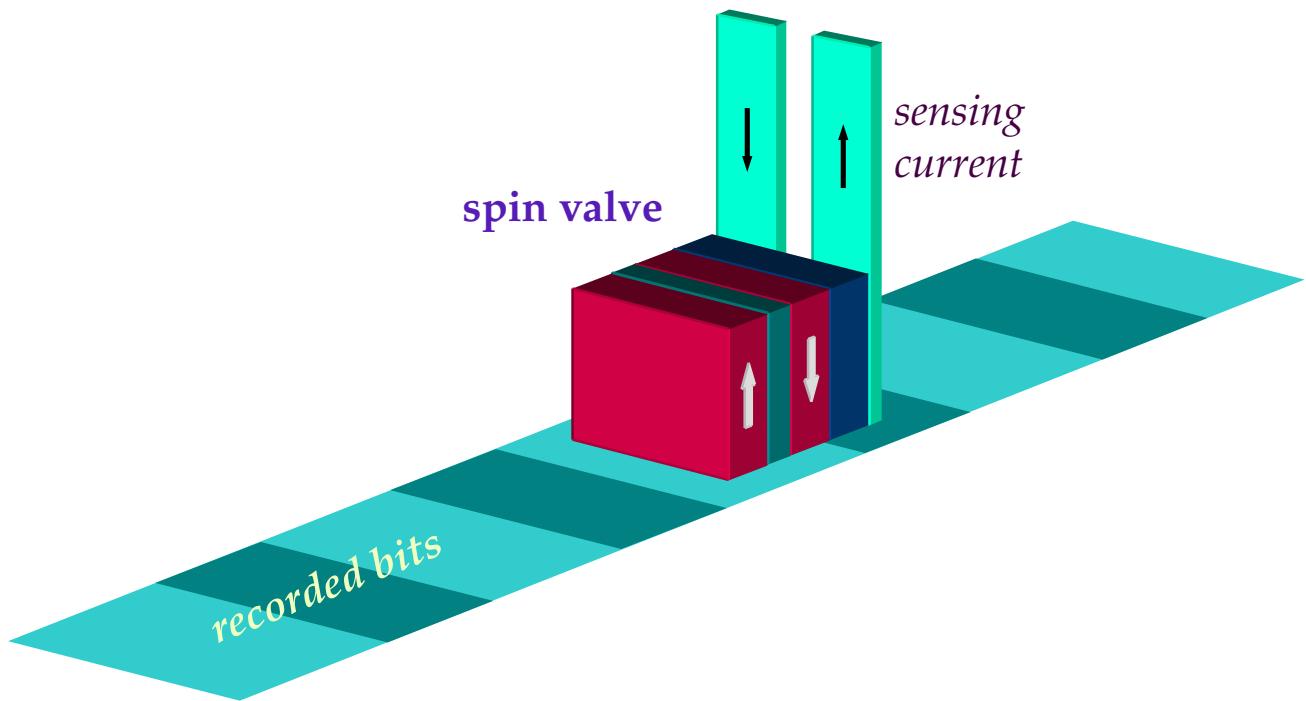
Granular material



Spin valve



Magnetic field sensor

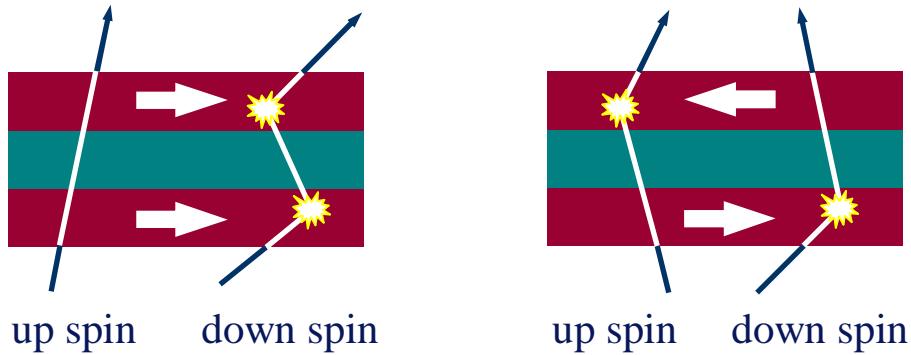


Simple model for GMR

Two-current model:

$$\rho_{\text{tot}} = \rho_{\uparrow} - \text{up spins} + \rho_{\downarrow} - \text{down spins}$$

In ferromagnets $\rho_{\uparrow} \neq \rho_{\downarrow}$



$$R_{\uparrow\uparrow} = \frac{\rho_{\uparrow}}{\rho_{\downarrow}} \quad R_{\uparrow\downarrow} = \frac{\rho_{\uparrow}}{\rho_{\downarrow}}$$

$$\text{GMR} = \frac{(\rho_{\downarrow} - \rho_{\uparrow})^2}{4\rho_{\downarrow}\rho_{\uparrow}} = \frac{(\alpha - 1)^2}{4\alpha}$$

$\alpha = \frac{\rho_{\downarrow}}{\rho_{\uparrow}}$ is spin asymmetry parameter

Electrical conduction in metals

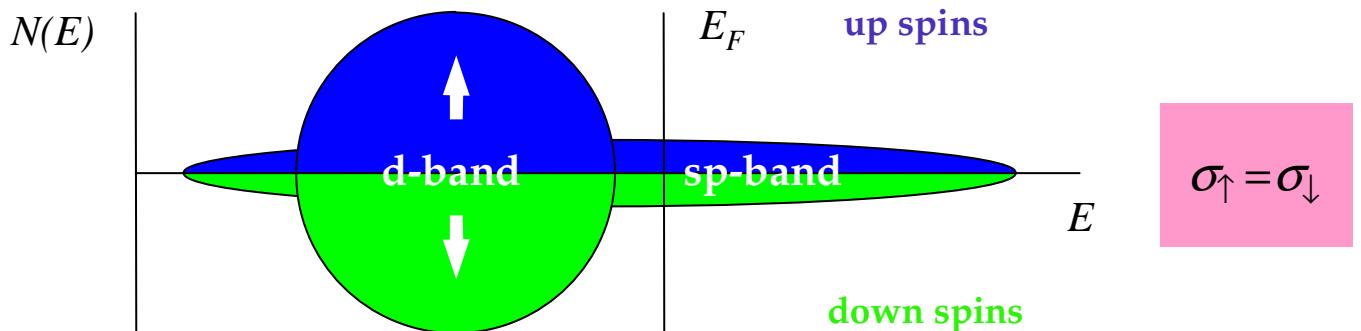
Drude formula

$$\sigma = \frac{ne^2\tau}{m} = \frac{e^2}{\pi\hbar} \frac{k_F^2}{3\pi} l_{mfp}$$

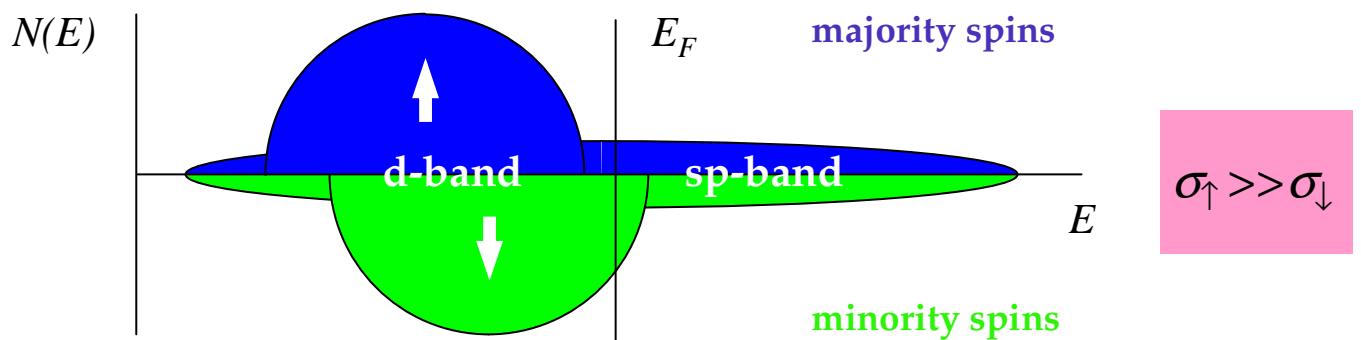
Mean free path

$$l_{mfp} = v_F \tau = v_F \frac{\hbar}{2\pi} \frac{1}{V_{scat}^2 N_F}$$

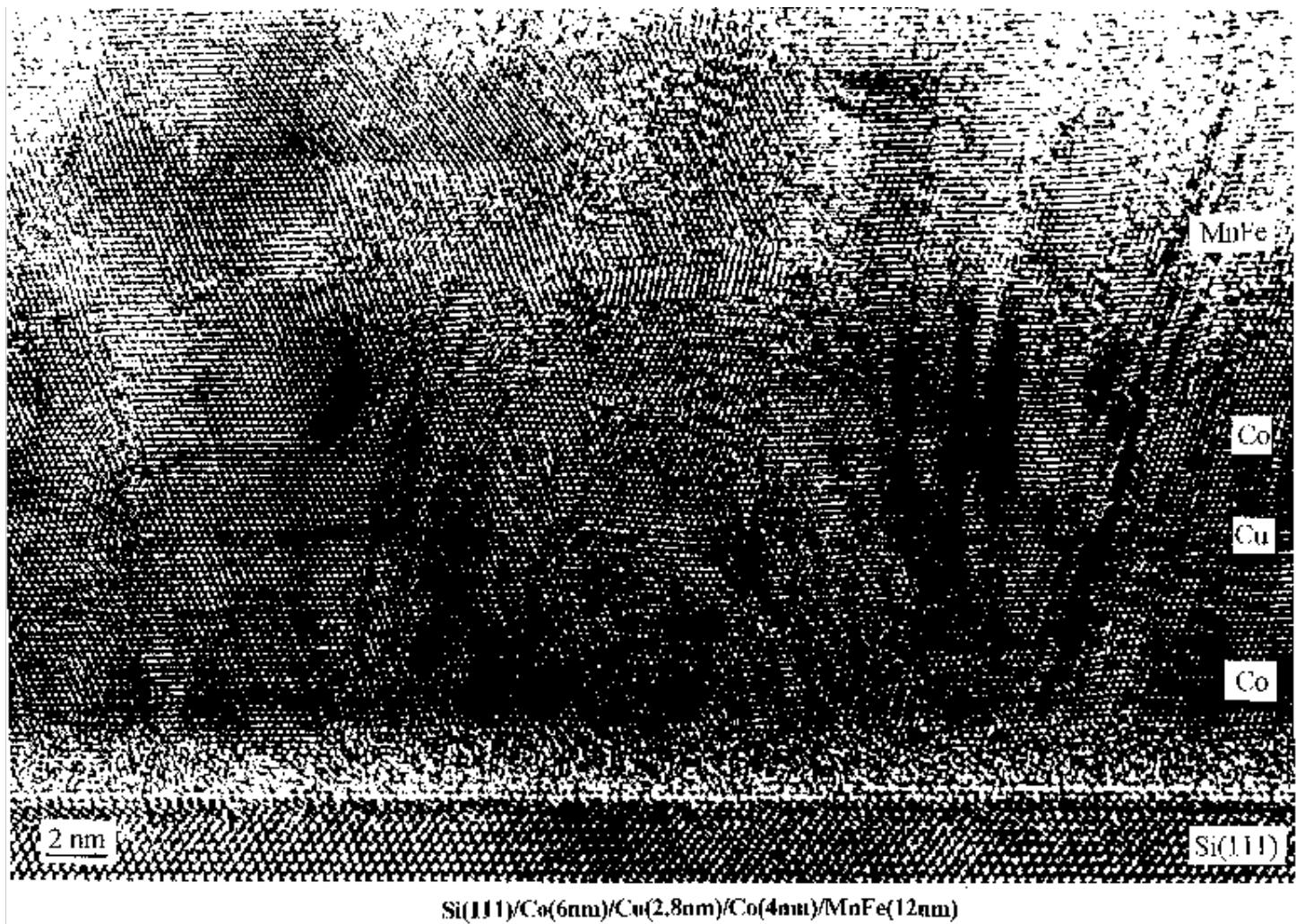
Nonmagnetic metal (Cu)



Magnetic metal (Co)



High resolution electron micrograph of Co/Cu spin valve



P.Baile-Guillemaud, A.K.Petford-Long

The theoretical model for GMR

Phys.Rev.B 54, 15314 (1996)

- ◆ Realistic electronic band structure
- ◆ Scattering is due to structural defects within a multilayer

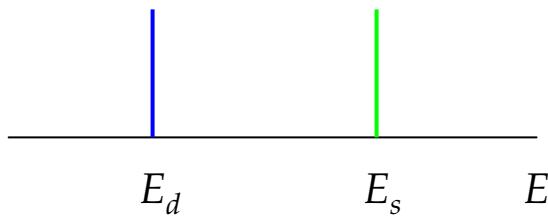
Kubo-Greenwood formula:

$$\sigma = \frac{\pi \hbar e^2}{\Omega} \text{Tr} \langle v \delta(E_F - H) v \delta(E_F - H) \rangle$$

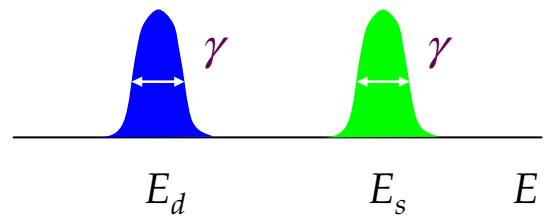
$$H = H_0 + V_{scat}$$

V_{scat} - scattering potential
effecting on-site atomic energy levels randomly

Perfect lattice:

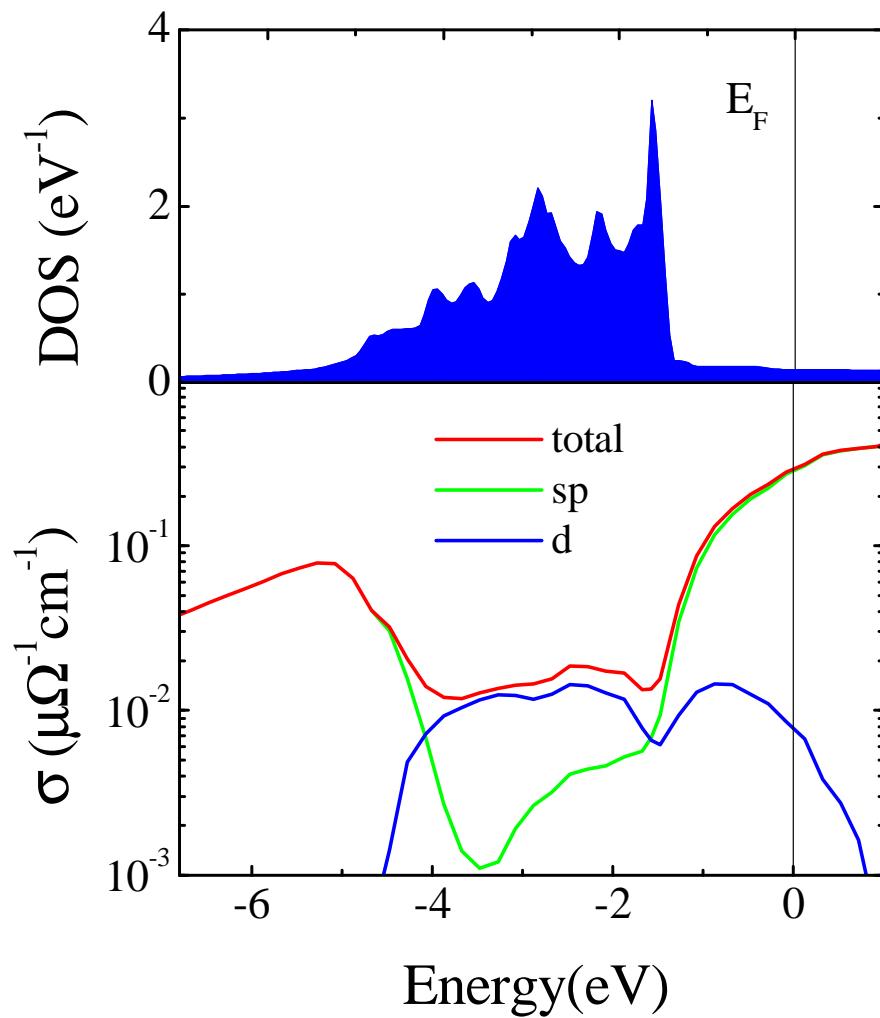


Defective lattice:

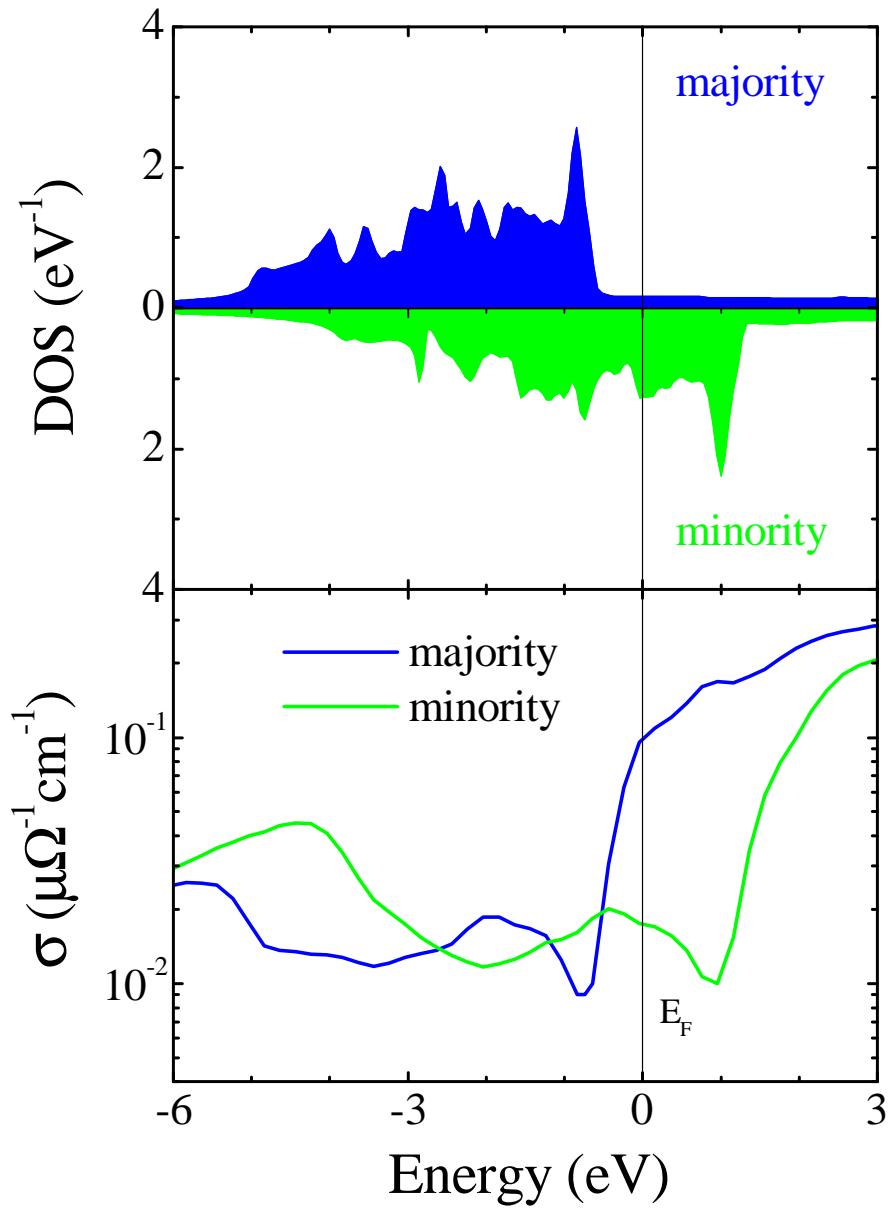


- γ is assumed to be spin-independent

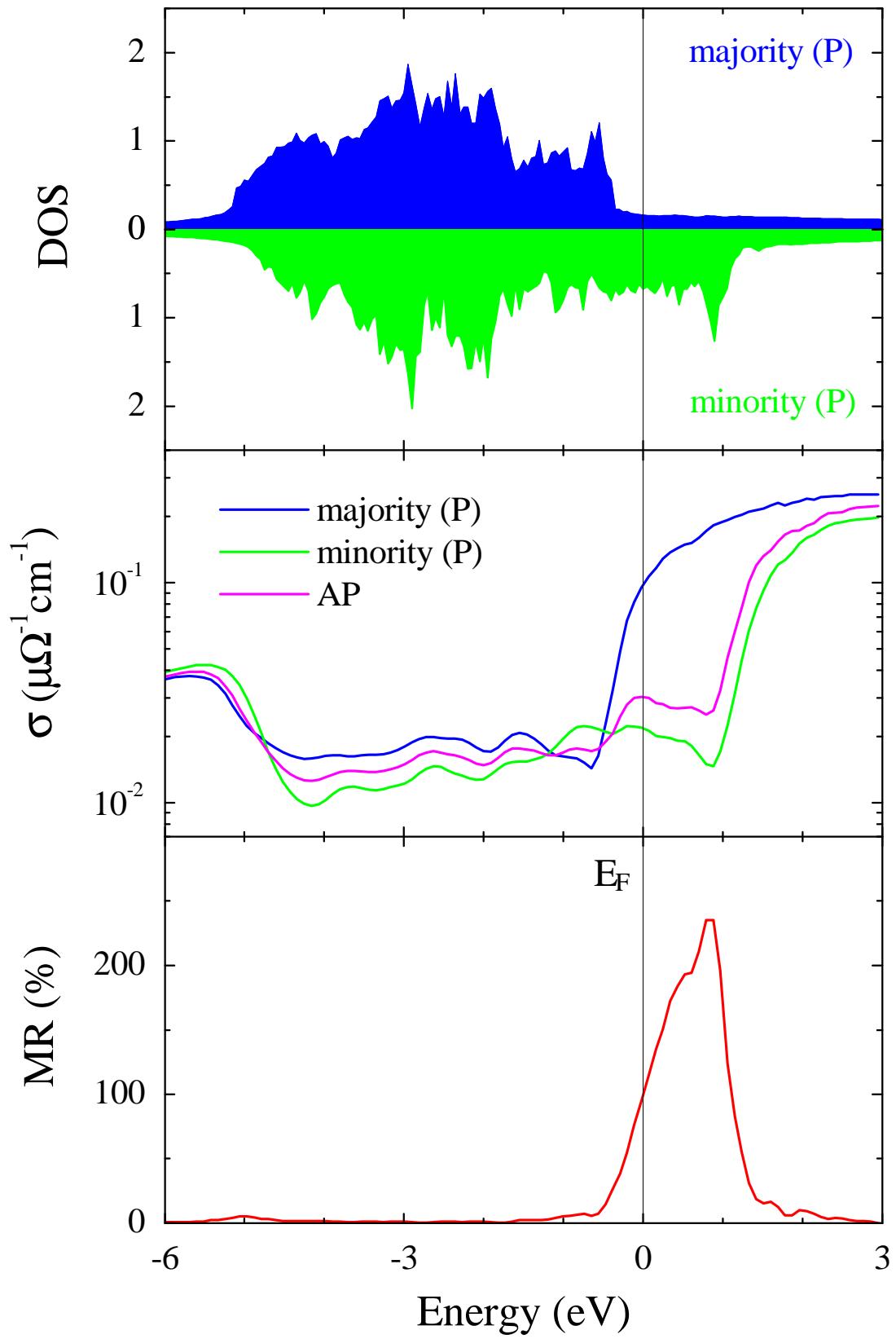
Conductivity of bulk Cu



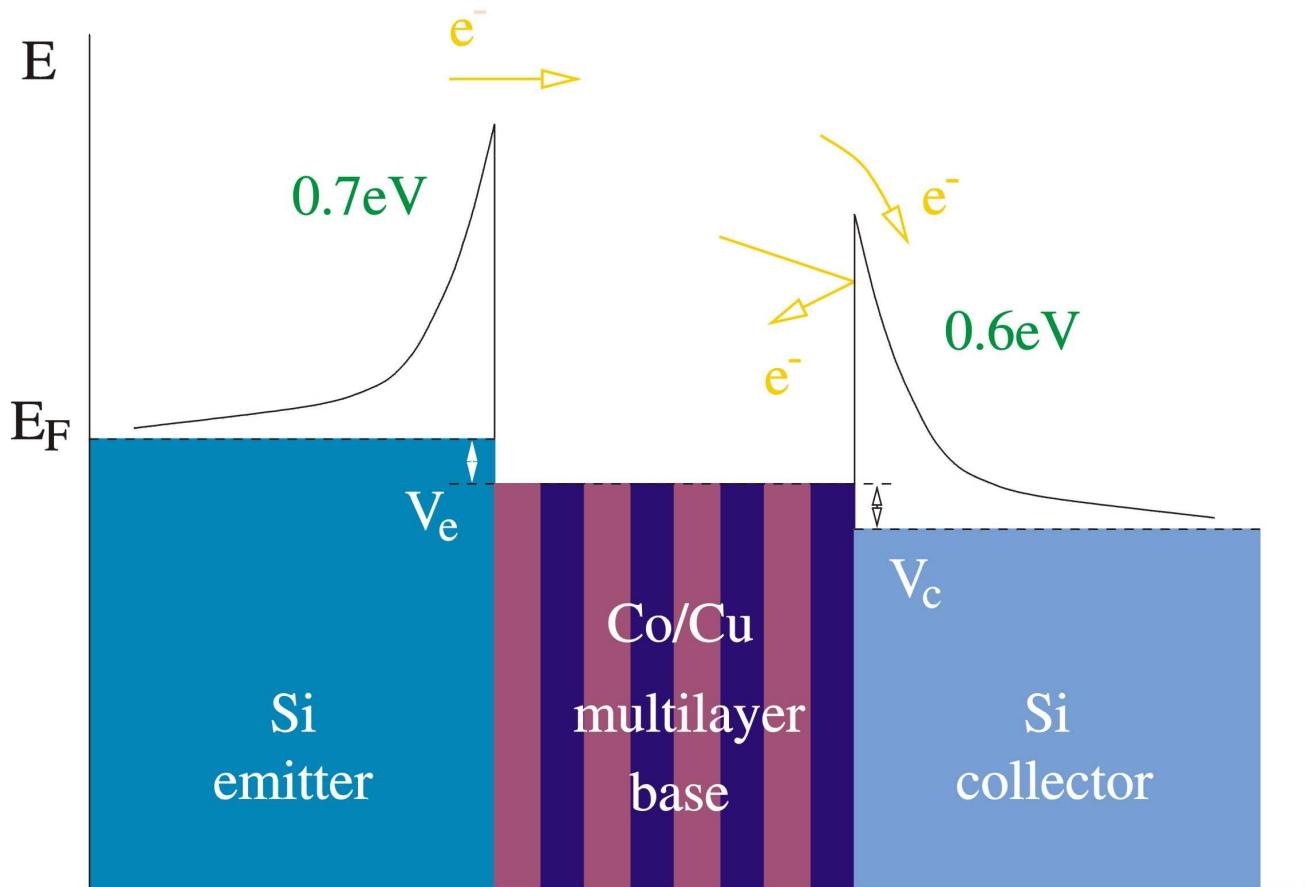
Conductivity of bulk Co



Co/Cu multilayer

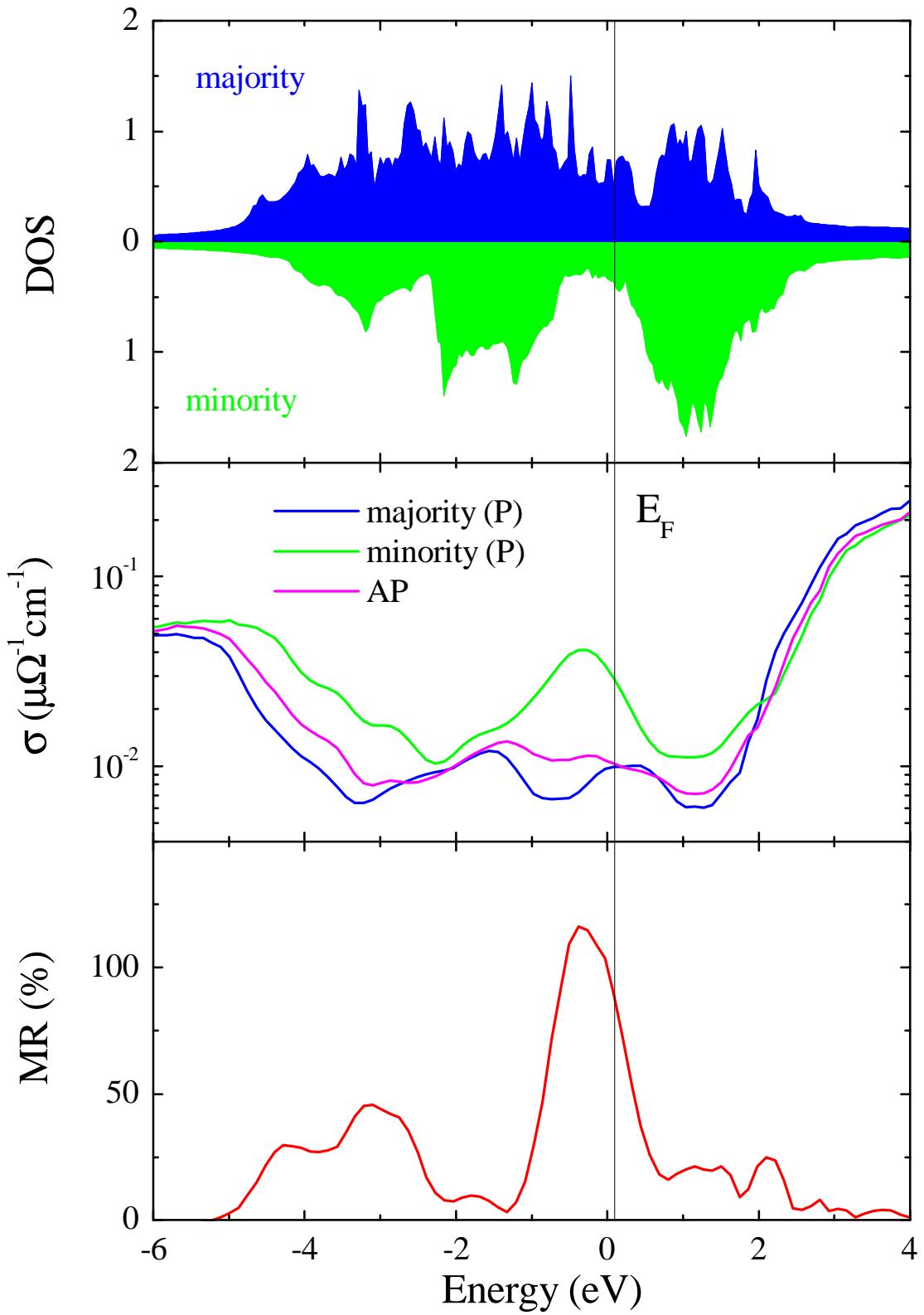


Spin-valve transistor



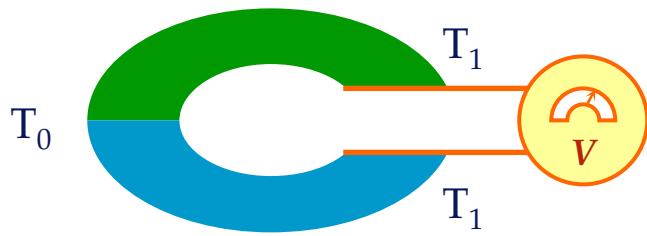
D.J.Monsma et al, Phys.Rev.Lett. 74, 5260 (1995)

Fe/Cr multilayer



Thermoelectric power (TEP)

PRB 59, 8371 (1999)



Experiments:

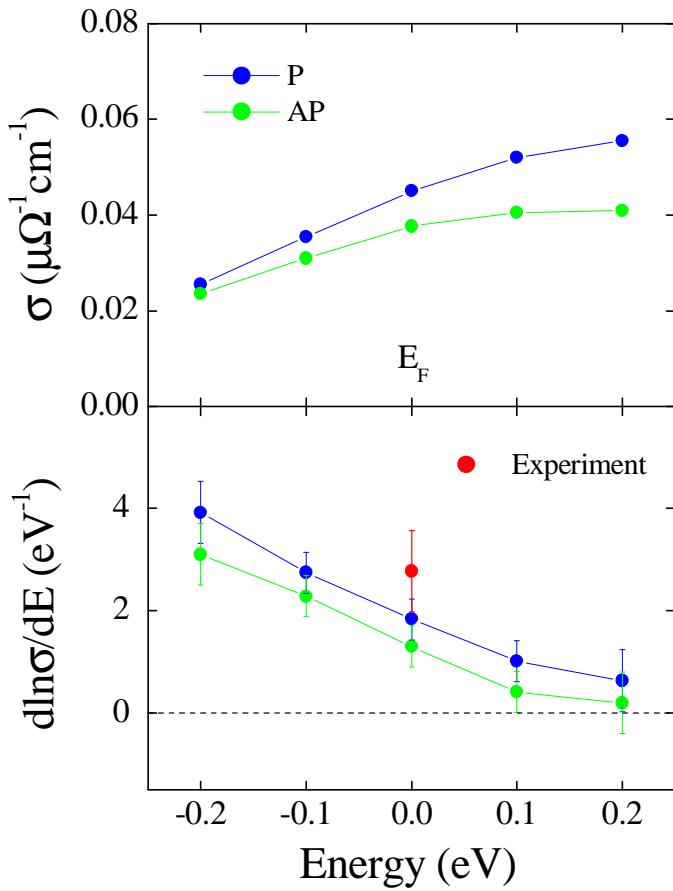
J.Shi, *Motorola Research Labs*
M.Salamon, *University of Illinois*

- ◆ Experimentally TEP and magneto-TEP is **negative** for Co/Cu multilayers, but **positive** for Fe/Cr multilayers

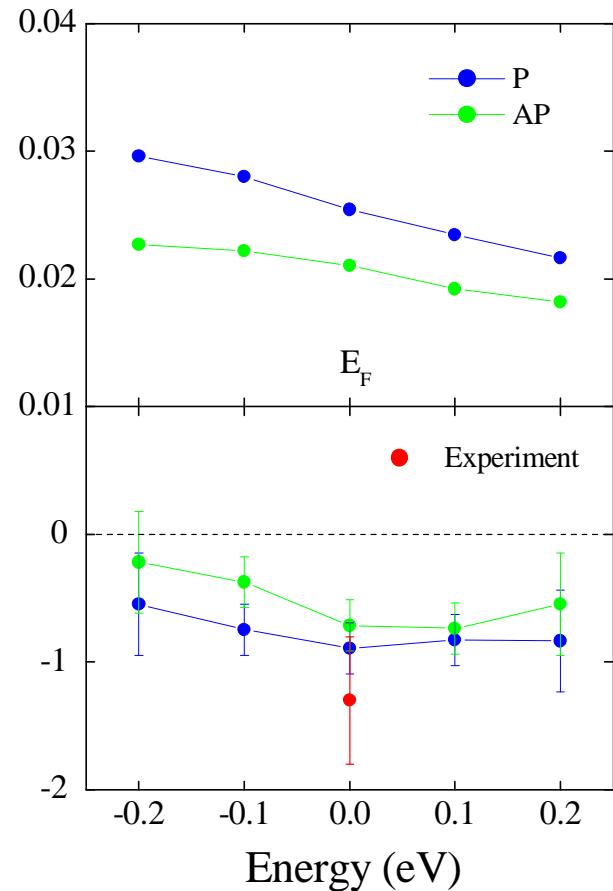
Mott formula:

$$S = -\frac{\pi^2 k^2 T}{3e} \left. \frac{\partial \ln \sigma}{\partial E} \right|_{E_F}$$

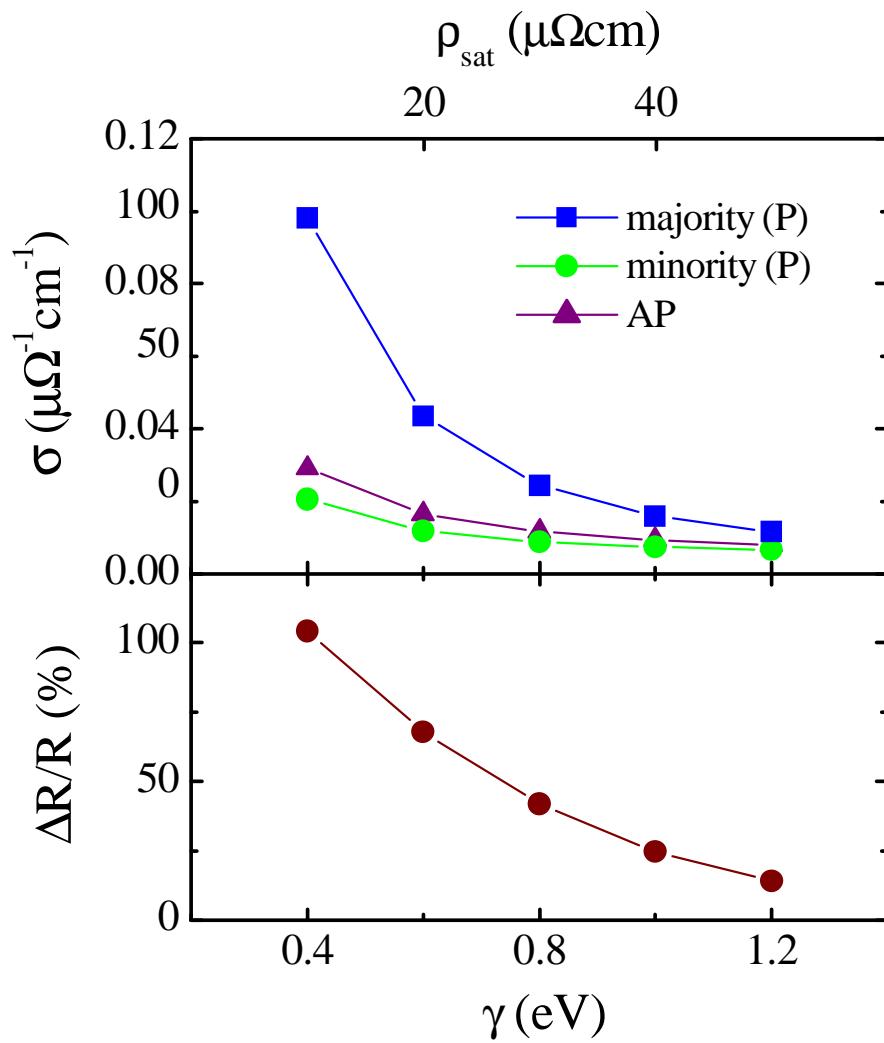
Co/Cu multilayer



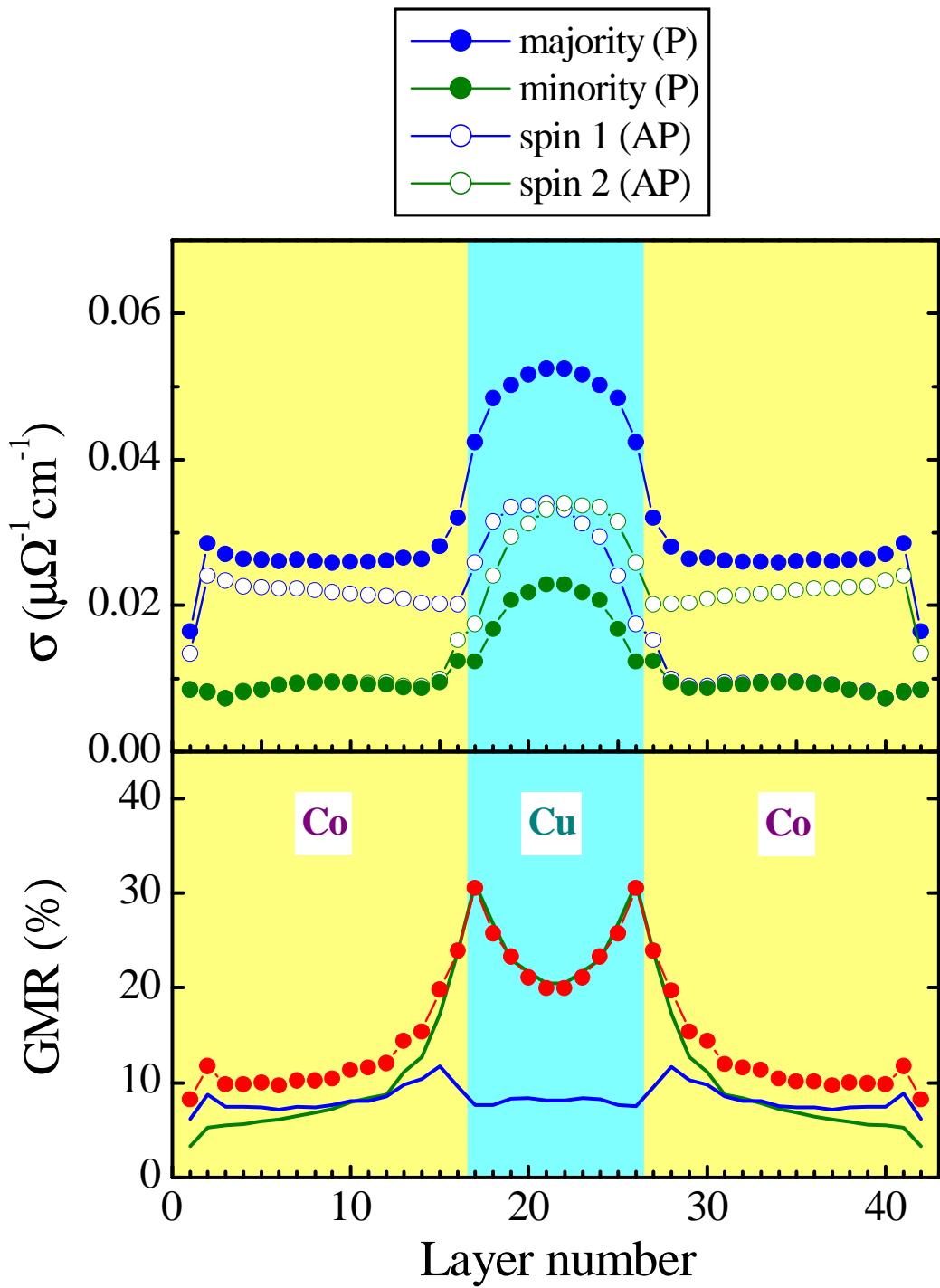
Fe/Cr multilayer



Effect of disorder



Layer-dependent conductance



- bulk disorder
- bulk & outer-boundary disorder
- bulk & interface disorder

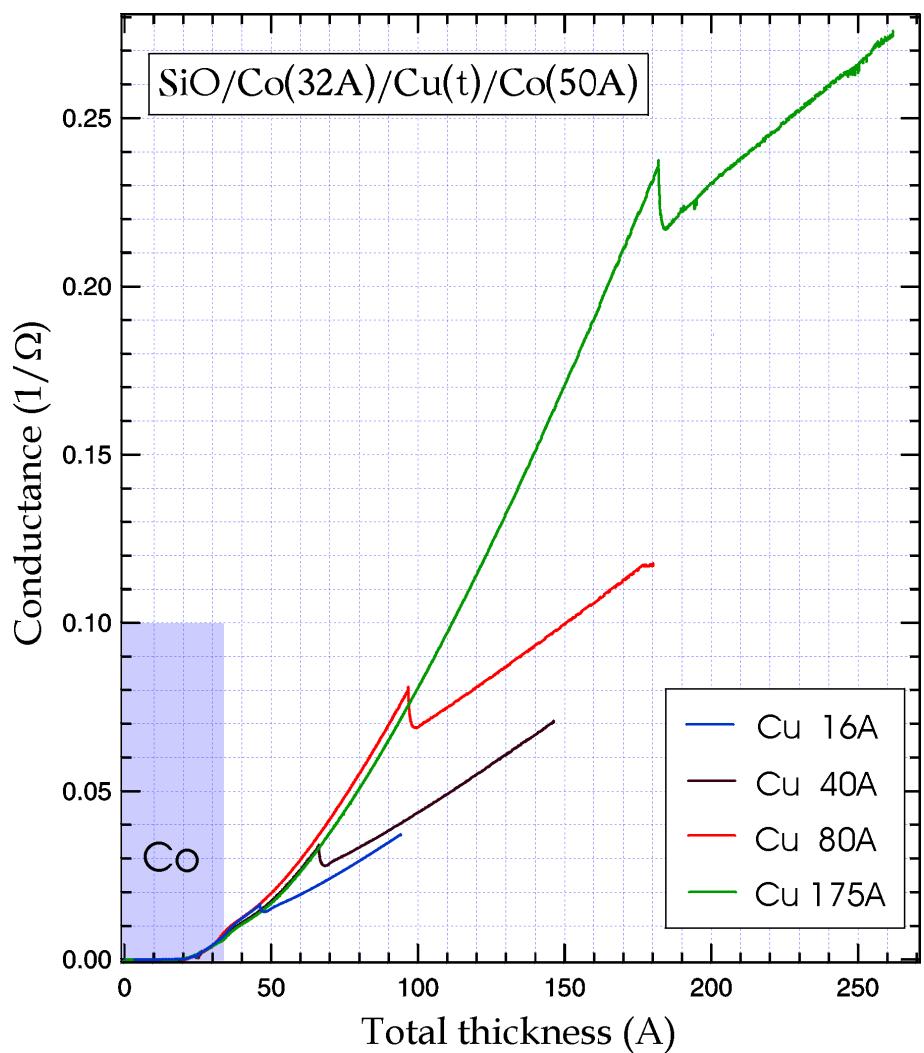
Thickness-dependent conductance

PRB 61, 1330 (2000)

Experiments:

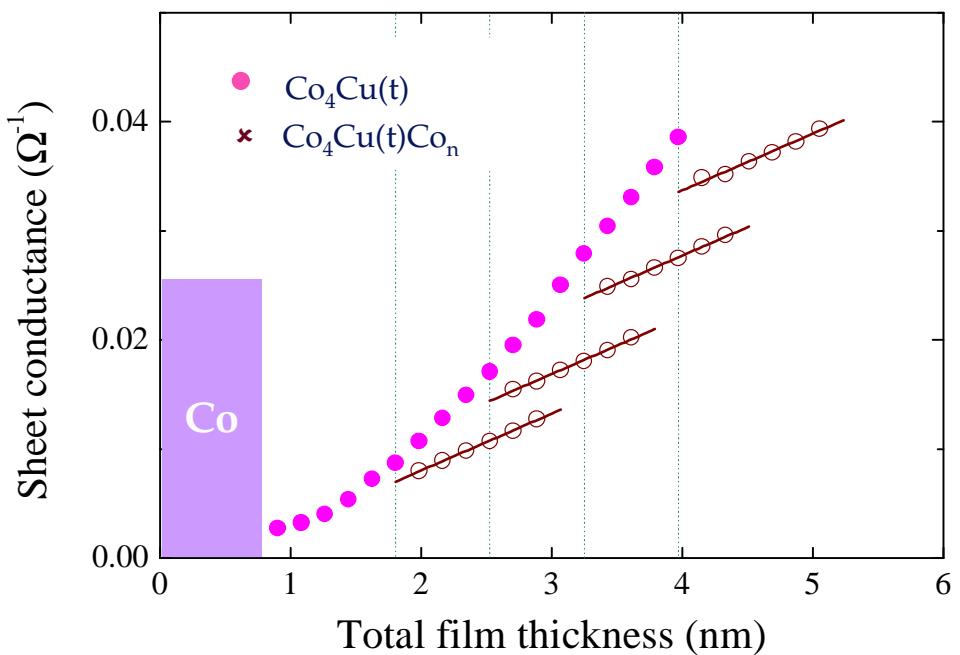
W.Bailey and S.Wang,
Stanford University

Conductance is
measured *in situ*
during ion-beam
deposition



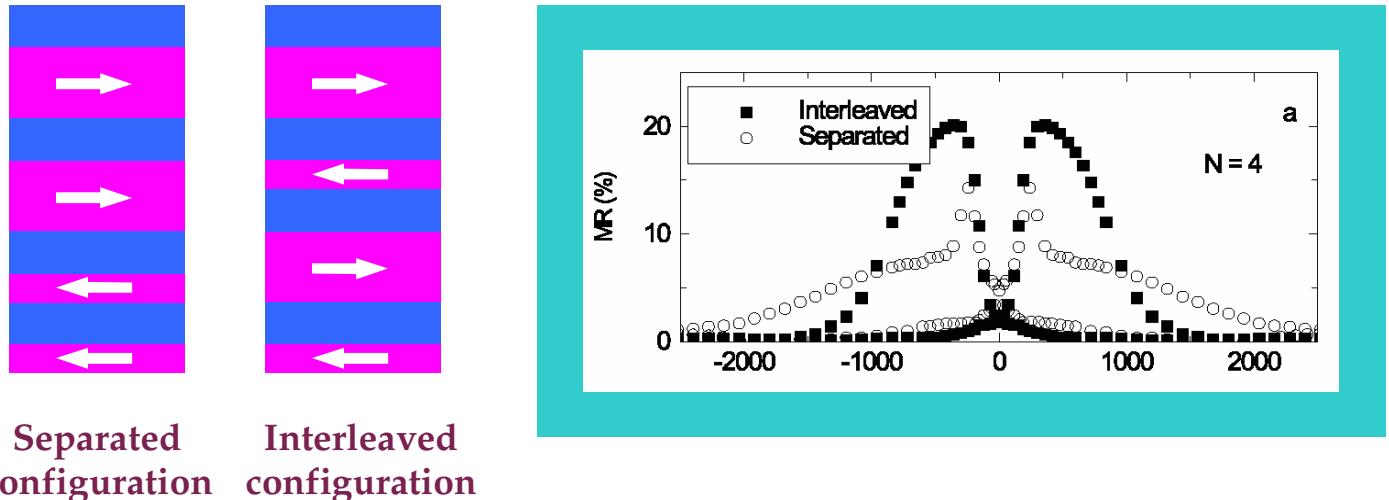
Theory:

Conductance drop
results from strong
interface scattering,
as a consequence of
high density of
empty Co d states
at Cu boundaries



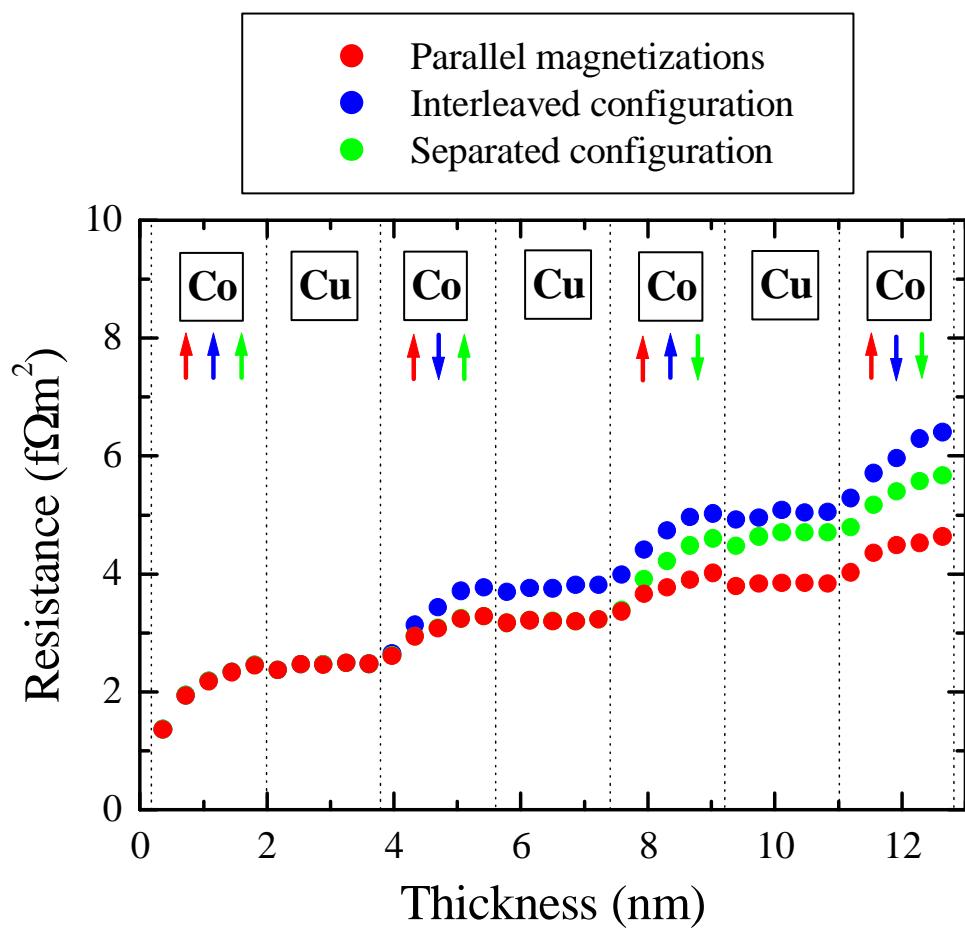
Failure of resistor model for CPP GMR

Experiments: D. Bozec *et al*, University of Leeds



Separated configuration Interleaved configuration

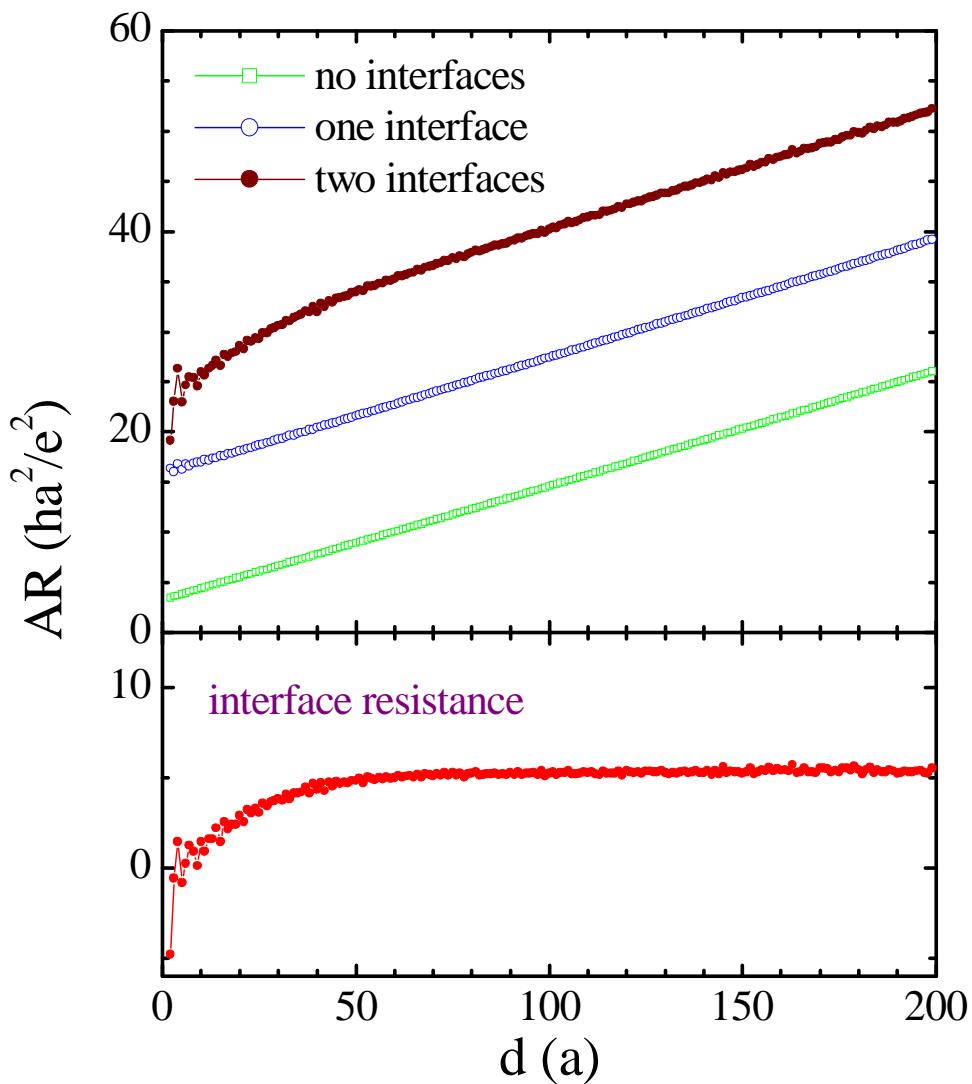
Theory:



Layer-thickness-dependent interface resistance

PRB 61, 506 (2000)

- ◆ single-band tight-binding model
- ◆ Kubo formula within Anderson model of disorder
- ◆ two different metals, characterized by different on-site atomic energies



Conclusions

The model for giant magnetoresistance

predicts

- Decreasing GMR with disorder
- Enhancement of GMR in Co/Cu multilayers for hot electrons; no such enhancement for Fe/Cr multilayers
- Sizeable contribution from the spacer layer in spin valves
- Importance of layer-thickness-dependent interface resistance for CPP GMR

and explains

- Thermoelectric power in Co/Cu and Fe/Cr multilayers
- Conductance of in-situ grown Co/Cu spin valves
- Failure of the resistor model for CPP GMR